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Hsu et al.

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(54) **SUBSTRATE AND DISPLAY DEVICE HAVING THE SAME**

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G02F 1/1337 (2006.01)

B82Y 20/00 (2011.01)

(52) **U.S. Cl.**

CPC **G02F 1/13439** (2013.01); **Y10S 977/788** (2013.01); **Y10S 977/952** (2013.01); **B82Y 20/00** (2013.01); **G02F 1/133707** (2013.01)

(58) **Field of Classification Search**

USPC 349/143, 129, 111
See application file for complete search history.

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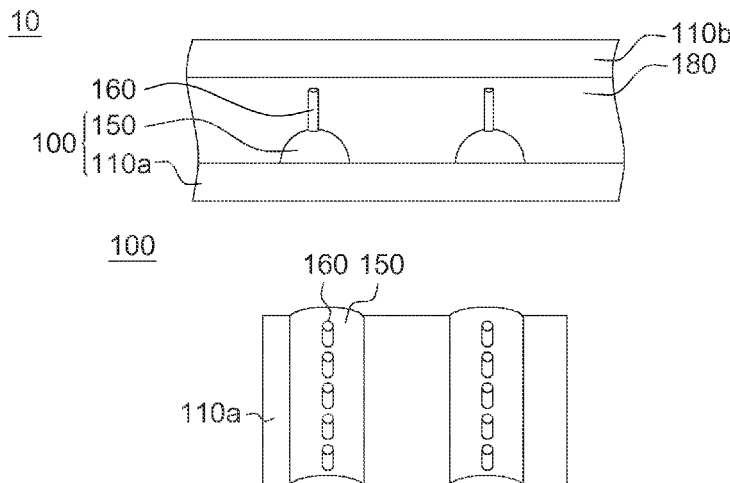
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(57) **ABSTRACT**

A display device includes a first base substrate, a second base substrate, a liquid crystal layer, a conductive protrusion structure and an electrode structure. The second base substrate is disposed opposite to the first base substrate. The liquid crystal layer is disposed between the first and second base substrates. The conductive protrusion structure is disposed on one of the first and second base substrates. The electrode structure is at least disposed on the first or second base substrate having the conductive protrusion structure.

18 Claims, 11 Drawing Sheets



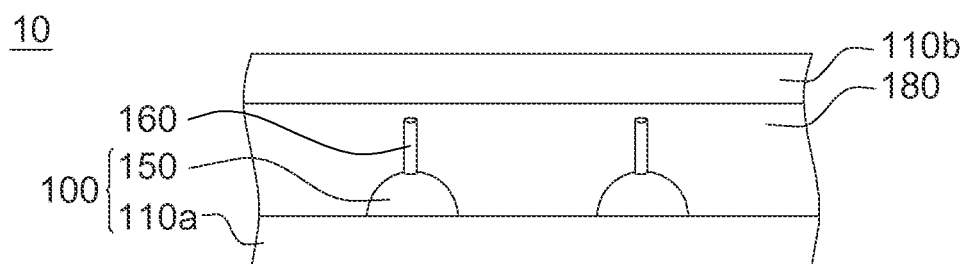


FIG. 1A

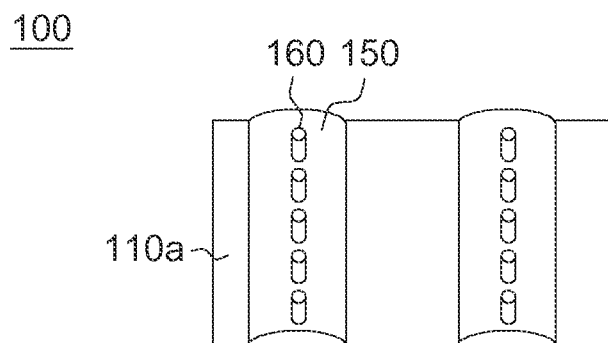


FIG. 1B

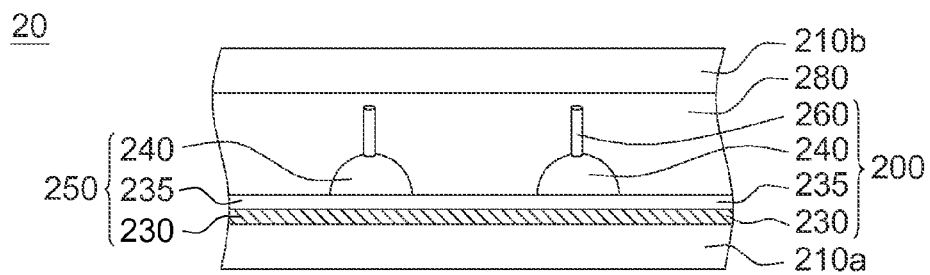


FIG. 2

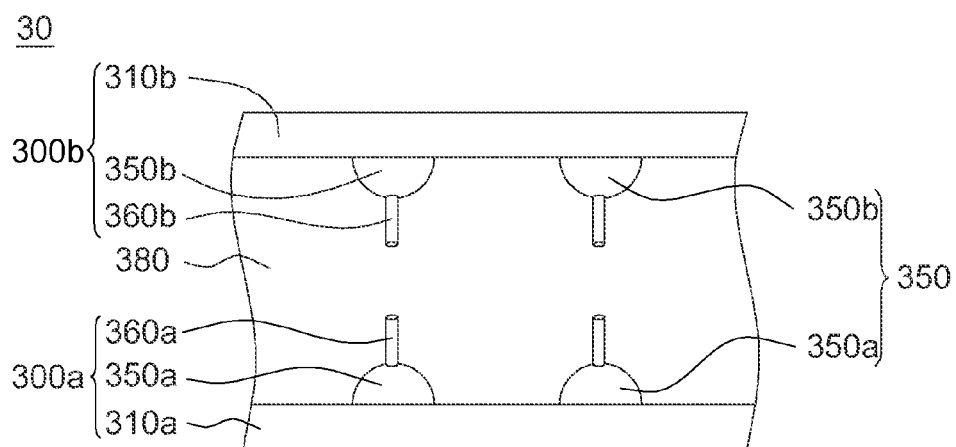


FIG. 3

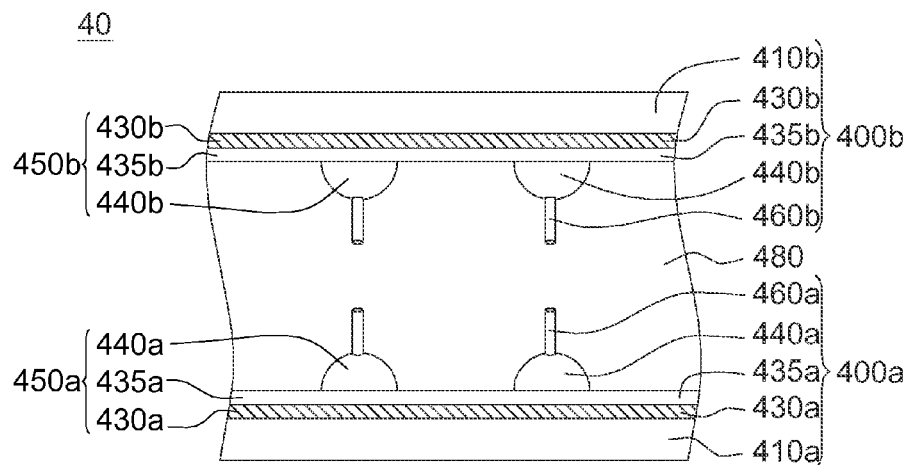


FIG. 4

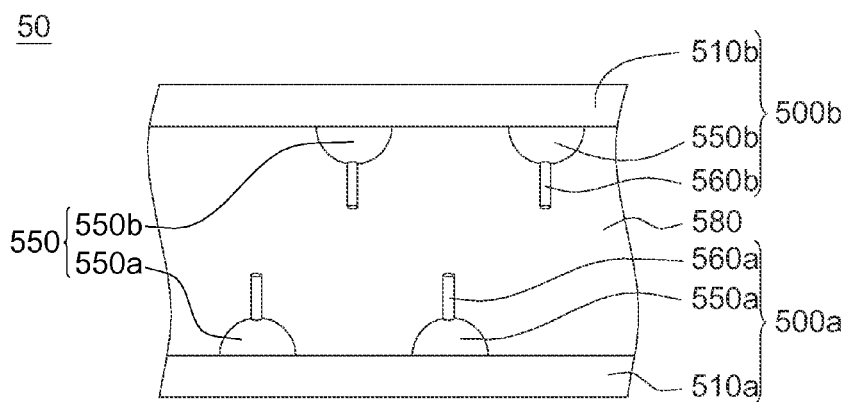


FIG. 5

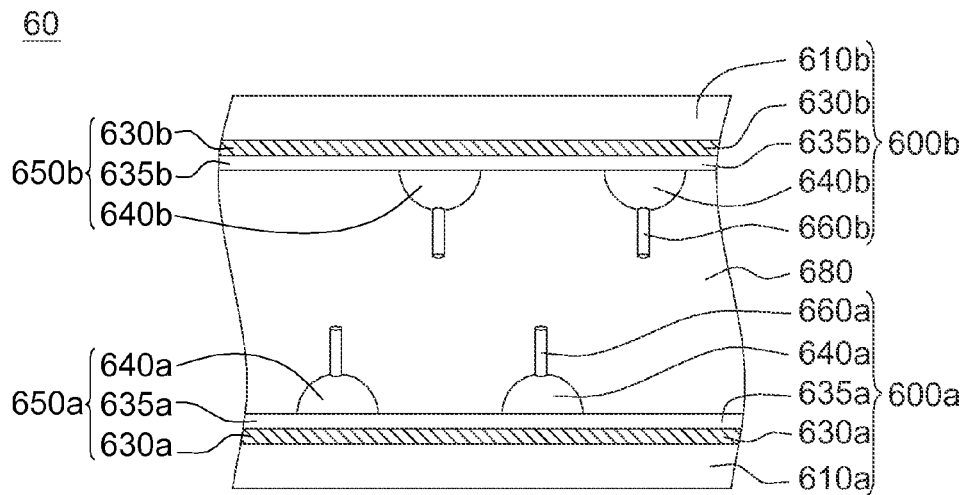


FIG. 6

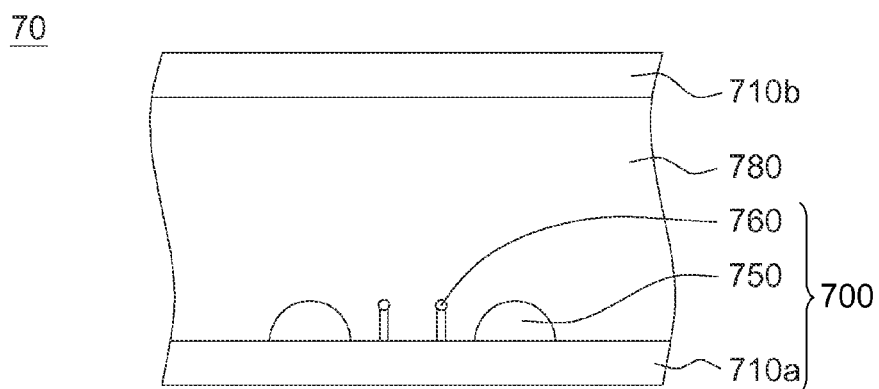


FIG. 7

80

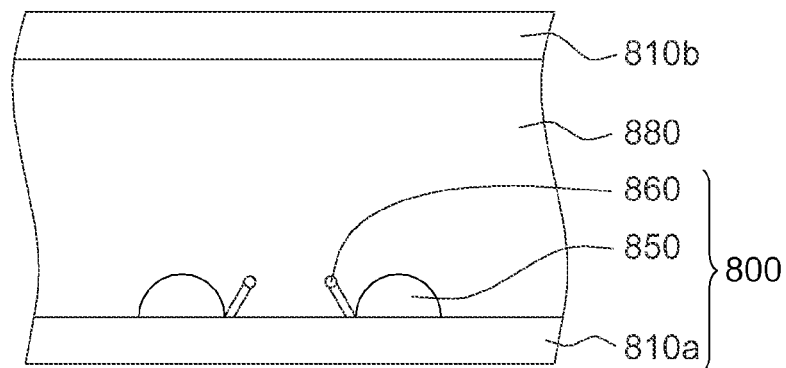


FIG. 8

90

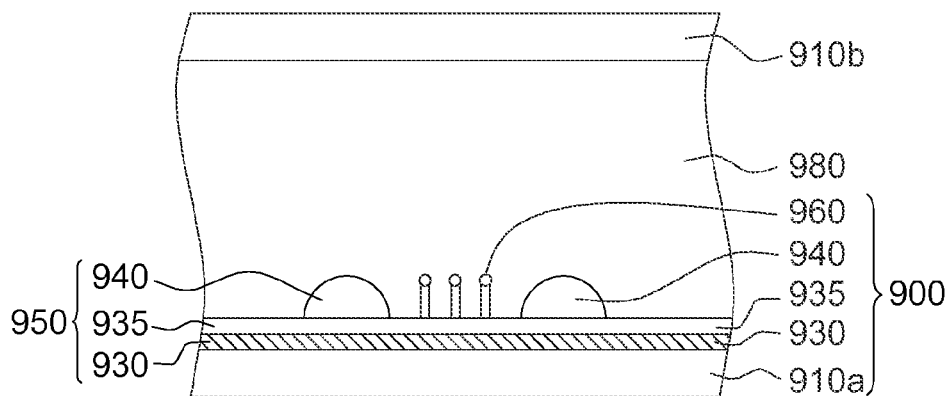


FIG. 9

1000

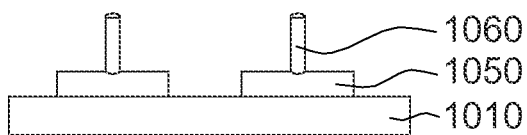


FIG. 10A

1000

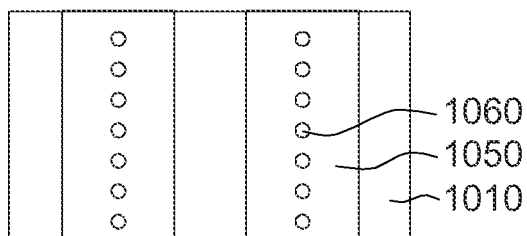


FIG. 10B

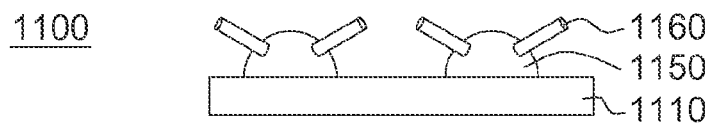


FIG. 11A

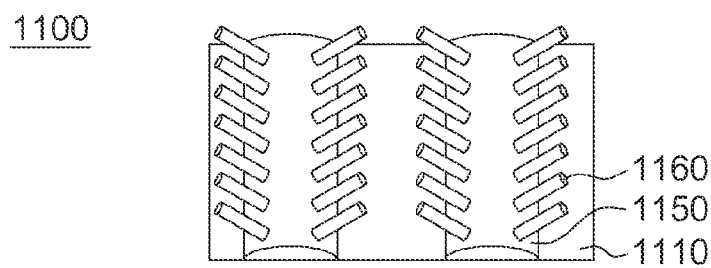


FIG. 11B

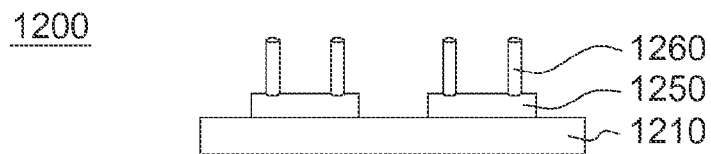


FIG. 12A

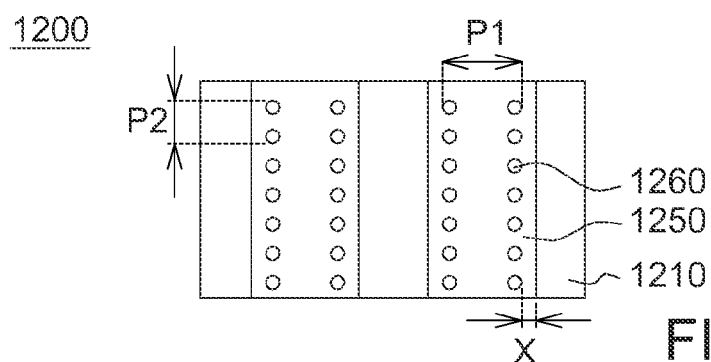


FIG. 12B

1300

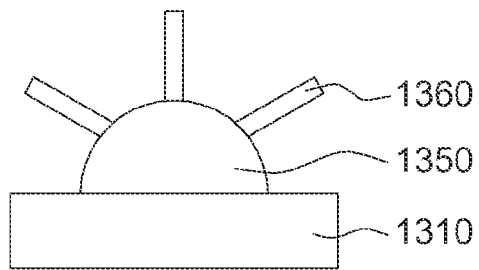


FIG. 13

1400

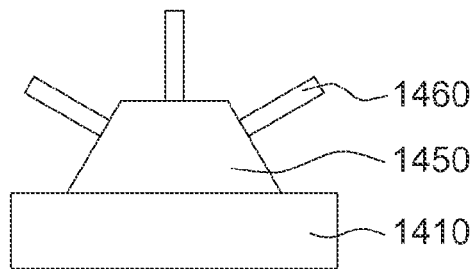


FIG. 14

1500

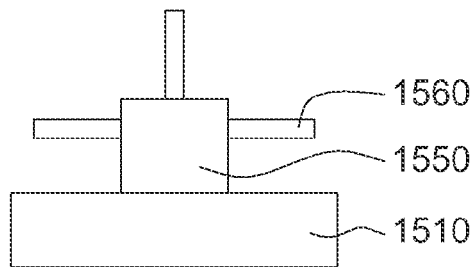


FIG. 15

1600

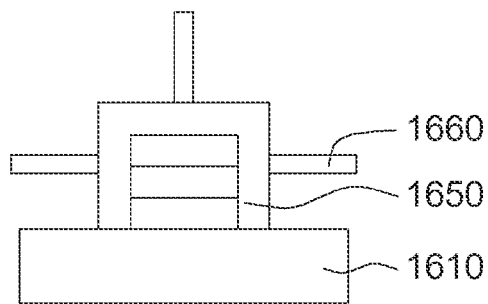


FIG. 16

1700

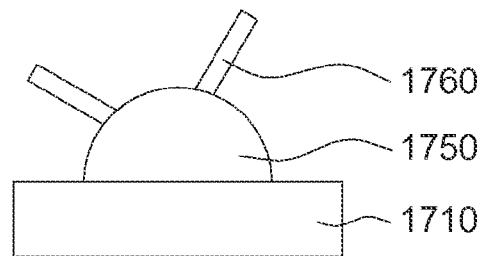


FIG. 17

1800

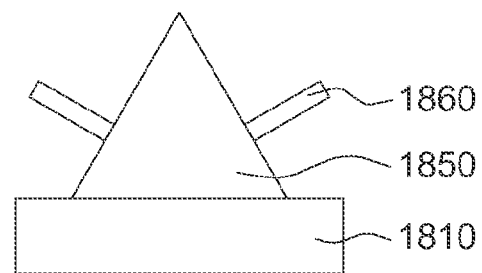


FIG. 18

1900

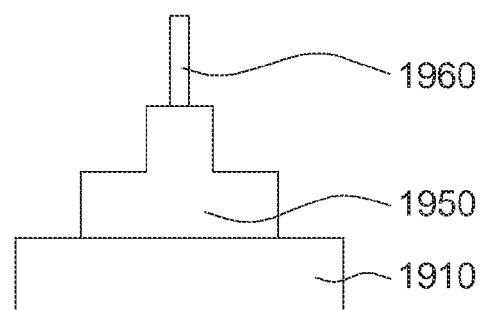


FIG. 19

2060a



FIG. 20A

2060b

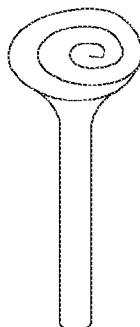


FIG. 20B

2060c

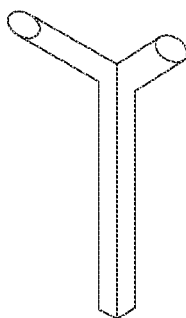


FIG. 20C

2060d

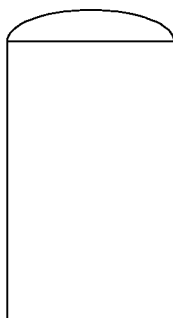


FIG. 20D

2060e

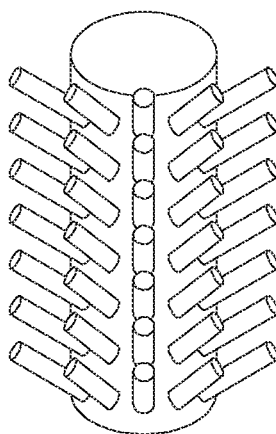


FIG. 20E

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SUBSTRATE AND DISPLAY DEVICE HAVING THE SAME

This application claims the benefit of Taiwan application Serial No. 101122790, filed Jun. 26, 2012, the subject matter of which is incorporated herein by reference.

BACKGROUND

1. Field of the Invention

The invention relates in general to a substrate having a conductive protrusion structure, and more particularly to a display device having the same.

2. Description of the Related Art

Liquid crystal displays (LCDs) are prevalent as display screens of electronic products in the recent years. LCDs are available in various forms including twister nematic, super twisted nematic (STN), in-plane switching (IPS), and multi-domain vertical alignment (MVA).

When applying a voltage to electrodes of an LCD, a rotational direction of liquid crystal molecules can be controlled to modulate a polarization direction of light, such that the intensity of light passing through the liquid crystal molecules is affected to further result in a contrast between a bright state and a dark state to serve as a display image.

To control the direction of liquid crystal molecules, a conventional display based on nematic liquid crystals usually processes surface alignment of a substrate to control alignment of the liquid crystal molecules. For example, the liquid crystals proceed with a rubbing process, in which an alignment film surface applied to a surface of the substrate in contact with the liquid crystals is rubbed. However, such rubbing process not only increases production costs but also reduces the display quality. Moreover, due to a long response time, the foregoing LCD based on nematic liquid crystals is unfavorable in applications for displaying dynamic graphics in sequential colors, and a color filter film is additionally required for presenting display effects of different colors. As a result, production costs and manufacturing complications of LCDs based on nematic liquid crystals are high.

Therefore, blue phase liquid crystals having a fast response speed is one research focus of industrial developers. Blue phase LCDs offer advantages of having a fast response speed, high contrast and a wide viewing angle. Yet, blue phase liquid crystals can only be driven by a higher voltage, which is one of the issues to be overcome in developing blue phase LCD devices.

SUMMARY

The disclosure is directed to a substrate and a display device having the substrate. The substrate includes an electrode structure and a conductive protrusion structure, and is capable of increasing and extending a range of an operating electric field as well as lowering a driving voltage of the display device.

According to an aspect the disclosure, a display device is provided. The display device includes a first base substrate, a second base substrate, a liquid crystal layer, a conductive protrusion structure and an electrode structure. The second base substrate is disposed opposite to the first base substrate. The liquid crystal layer is disposed between the first and second base substrates. The conductive protrusion structure is disposed on one of the first and second base substrates. The electrode structure is disposed on at least one of the first and second base substrates having the conductive protrusion structure.

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According to another aspect of the disclosure, a substrate for a liquid crystal display (LCD) device is provided. The substrate includes a base substrate, an electrode structure and a conductive protrusion structure. The conductive protrusion structure is disposed on the base substrate. The electrode structure is disposed on the base substrate, and is adjacent to a liquid crystal layer of the LCD device.

The above and other aspects of the invention will become better understood with regard to the following detailed description of the preferred but non-limiting embodiments. The following description is made with reference to the accompanying drawings.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1A is a schematic diagram of a display device according to an embodiment of the present invention.

FIG. 1B is a top view of a substrate in FIG. 1A.

FIG. 2 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 3 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 4 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 5 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 6 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 7 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 8 is a sectional view of a display device according to an embodiment of the present invention.

FIG. 9 is a sectional view of a display device according to an embodiment of the present invention.

FIGS. 10A and 10B are schematic diagrams of a substrate according to an embodiment of the present invention.

FIGS. 11A and 11B are schematic diagrams of a substrate according to an embodiment of the present invention.

FIGS. 12A and 12B are schematic diagrams of a substrate according to an embodiment of the present invention.

FIGS. 13 to 19 are schematic diagrams of an electrode structure and conductive protrusion structures according to different embodiments of the present invention.

FIGS. 20A to 20E are schematic diagrams of a conductive protrusion structure according to different embodiments of the present invention.

DETAILED DESCRIPTION OF THE INVENTION

FIG. 1A shows a schematic diagram of a display device according to an embodiment of the present invention. Referring to FIG. 1A, a display device 10 includes a first base substrate 110a, a second base substrate 110b, an electrode structure 150, a conductive protrusion structure 160 and a liquid crystal layer 180. The second base substrate 110b is disposed opposite to the first base substrate 110a. The electrode structure 150 is disposed on the first base substrate 110a having the conductive protrusion structure 160. For example, the electrode structure 150 includes a plurality of alternately arranged pixel electrodes and common electrodes. The conductive protrusion structure 160 is disposed on the first base substrate 110a. In one embodiment, the conductive protrusion structure 160 may be disposed between the pixel electrodes and common electrodes, or between a pixel electrode and a common electrode (as shown in FIG. 7). The liquid crystal layer 180 is disposed between the first base substrate 110a and the second base substrate 110b. The first base sub-

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strate **110a**, the electrode structure **150** and the conductive protrusion structure **160** constitute a substrate **100**.

In an embodiment, the conductive protrusion structure **160** includes a metal oxide or a carbon nano-material. The carbon nano-material is a group selected from carbon-based nano-material, nano carbon fiber and nano carbon graphite. For example, the conductive protrusion structure **160** may be a group selected from iron oxide, ferric oxide (Fe_2O_3), titanium dioxide (TiO_2), copper oxide (CuO) and indium tin oxide (ITO). In an embodiment, the conductive protrusion structure **160** includes a plurality of conductive protrusions having a thickness between 10 nm to 1 μm and a length between 100 nm and 10 μm . The conductive protrusions are evenly distributed in a way that the conductive protrusion structure **160** may have a density of 10^{-2} to 10^6 conductive protrusions per 100 μm^2 . When a voltage is applied to the electrode structure **150**, the conductive protrusion structure **160** being affected by an electric field of the electrode structure **150**, becomes electrically conductive so that a range of an operating electric field can be extended to provide an expanded effective electric field for more effectively controlling the liquid crystal molecules.

FIG. 1B shows a top view of the substrate **100** in FIG. 1A. In this embodiment, for example, the electrode structure **150** is a semicircular or semi-ellipsoidal cylinder. In other embodiments, the electrode structure **150** may also be a T-shaped, trapezoidal, semi-spherical, rectangular or multi-layer composite structure. For example, the conductive protrusion structure **160** includes a plurality of minute rod shaped or pin shaped conductive protrusions evenly or unevenly distributed on an axis of symmetry of the electrode structure **150** to provide point discharge. In other embodiments, the conductive protrusion structure **160** may also be a hair shaped, forked shaped, needle shaped or column shaped structure. When applying a voltage to the electrode structure **150**, the conductive protrusion structure **160** is capable of extending the operating electric field and reducing a range of a dead zone. A dead zone means an insufficient electric which is too weak to drive the liquid crystal molecules. The shape and position of the conductive protrusion structure **160** may be adjusted to adapt to manufacturing or product requirements.

FIG. 2 shows a sectional view of a display device **20** according to an embodiment of the present invention. As shown in FIG. 2, the display device **20** includes a first base substrate **210a**, a second base substrate **210b**, an electrode structure **250**, a conductive protrusion structure **260** and a liquid crystal layer **280**. The second base substrate **210b** is disposed opposite to the first base substrate **210a**. The electrode structure **250** includes a first electrode **230**, an insulation layer **235** and a second electrode **240**. The first electrode **230** is disposed on the first base substrate **210a**. The insulation layer **235** is disposed on the first electrode **230**. The second electrode **240** is disposed on the insulation layer **235**. The conductive protrusion structure **260** is disposed on the second electrode **240**. In this embodiment, for example, the length, density and material of the conductive protrusion structure **260** is substantially equal to those of the conductive protrusion structure **160** in FIGS. 1A and 1B, and associated details shall be omitted herein.

In this embodiment, the first base substrate **210a**, the insulation layer **235**, the electrode structure **250** and the conductive protrusion structure **260** constitute a substrate **200**. In FIG. 2, the conductive protrusion structure **260** is depicted as being disposed on the axis of symmetry of the second electrode **240**, and may, however, be disposed at other positions of the second electrode **240**. Alternatively, the conductive pro-

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trusion structure **260** may also be disposed between two second electrodes **240** on the insulation layer **235**. By applying voltages having different polarities to the two adjacent second electrodes **240**, the two sides of the conductive protrusion structure **260** may carry electricity having different polarities as being induced by the second electrodes **240** to improve the intensity of the local electric field.

FIG. 3 shows a sectional view of a display device **30** according to an embodiment of the present invention. The display device **30** includes a first base substrate **310a**, a second base substrate **310b**, an electrode structure **350a**, an electrode structure **350b**, a conductive protrusion structure **360a**, a conductive protrusion structure **360b** and a liquid crystal layer **380**. The second base substrate **310b** is disposed opposite to the first base substrate **310a**. The electrode structure **350** includes the first electrode **350a** and the second electrode **350b**. The first electrode **350a** is disposed on the first base substrate **310a**, and the second electrode **350b** is disposed on the second base substrate **310b**. The conductive protrusion structure **360a** is disposed on the second electrode **350a**, and the conductive protrusion structure **360b** is disposed on the second electrode **350b**.

In this embodiment, the conductive protrusion structures **360a** and **360b** have substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. 1A and 1B, and associated details shall be omitted herein. The first base substrate **310a**, the electrode structure **350a** and the conductive protrusion structure **360a** constitute a substrate **300a**; the second base substrate **310b**, the electrode structure **350b** and the conductive protrusion structure **360b** constitute a substrate **300b**. The substrates **300a** and **300b** may have similar structures and be arranged in a symmetrical manner. In other embodiments, the substrates **300a** and **300b** may have different structures and be arranged in a non-symmetrical manner. For example, the conductive protrusion structure may be disposed at one of the substrate, e.g., only one of the substrates **300a** and **300b** is disposed with the conductive protrusion structure. That is to say, the conductive protrusion structure **360a** or the conductive protrusion structure **360b** may be disposed on at least one of the electrode structure **350a** of the substrate **300a** and the electrode structure **350b** of the substrate **300b**.

In FIG. 3, the conductive protrusion structures **360a** and **360b** are depicted as respectively being disposed on the axes of symmetry of the electrode structures **350a** and **350b**. Given that the operating electric field of the electrode structures **350a** and **350b** can be extended by the conductive protrusion structures **360a** and **360b**, the conductive protrusion structures **360a** and **360b** may be disposed at other positions of the electrode structure **350a** and the electrode structure **350b**.

FIG. 4 shows a sectional view of a display device **40** according to an embodiment of the present invention. As shown in FIG. 4, the display device **40** includes a first base substrate **410a**, a second base substrate **410b**, an electrode structure **450a**, an electrode structure **450b**, a conductive protrusion structure **460a**, a conductive protrusion structure **460b** and a liquid crystal layer **480**. The second base substrate **410b** is disposed opposite to the first base substrate **410a**. The electrode structure **450a** includes a first electrode **430a**, an insulation layer **435a** and a second electrode **440a**. The first electrode **430a** is disposed on the first base substrate **410a**. The insulation layer **435a** is disposed on the first electrode **430a**. The second electrode **440a** is disposed on the insulation layer **435a**. The conductive protrusion structure **460a** is disposed on the second electrode **440a**. The electrode structure **450b** includes a first electrode **430b**, an insulation layer **435b** and a second electrode **440b**. The first electrode **430b** is disposed on

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the second base substrate **410b**. The insulation layer **435b** is disposed on the first electrode **430b**. The second electrode **440b** is disposed on the insulation layer **435b**. The conductive protrusion structure **460b** is disposed on the second electrode **440b**.

In this embodiment, the conductive protrusion structures **460a** and **460b** have substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. 1A and 1B, and associated details shall be omitted herein. The first base substrate **410a**, the insulation layer **435a**, the electrode structure **450a** and the conductive protrusion structure **460a** constitute a substrate **400a**. The second base substrate **410b**, the insulation layer **435b**, the electrode structure **450b** and the conductive protrusion structure **460b** constitute a substrate **400b**. In FIG. 4, the conductive protrusion structures **460a** and **460b** are respectively disposed on the axes of symmetry of the electrode structures **450a** and **450b**. However, the conductive protrusion structures **460a** and **460b** may also be disposed at other positions of the electrode structures **450a** and **450b**. Alternatively, the conductive protrusion structure **460a** or the conductive protrusion structure **460b** may also be disposed between two electrode structures **450a** on the insulation layer **435a** or two electrode structures **450b** on the insulation layer **435b**. By applying voltages having different polarities to the two adjacent electrode structures **450a** or electrode structures **450b**, the two sides of the conductive protrusion structure **460a** or the conductive protrusion structure **460b** may carry electricity having different polarities as being induced by the electrode structures **450a** or the electrode structures **450b** to improve the intensity of the local electric field.

FIG. 5 shows a sectional view of a display device **50** according to an embodiment of the present invention. The display device **50** includes a first base substrate **510a**, a second base substrate **510b**, an electrode structure **550**, a conductive protrusion structure **560a**, a conductive protrusion structure **560b** and a liquid crystal layer **580**. The first base substrate **510a** is disposed opposite to the first base substrate **510a**. The electrode structure **550** includes a first electrode **550a** and a second electrode **550b**. The first electrode **550a** is disposed on the first base substrate **510a**, and the second electrode **550b** is disposed on the second base substrate **510b**. The conductive protrusion structures **560a** and **560b** are respectively disposed on the second electrodes **550a** and **550b**.

In this embodiment, the conductive protrusion structures **560a** and **560b** have substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. 1A and 1B, and associated details shall be omitted herein. The first base substrate **510a**, the first electrode **550a** and the conductive protrusion structure **560a** constitute a substrate **500a**. The second base substrate **510b**, the second electrode **550b** and the conductive protrusion structure **560b** constitute a substrate **500b**.

In this embodiment, the structure of the substrate **500a** and the structure of the substrate **500b** may be the same or different. That is, the conductive protrusion structure may be disposed at only one of the substrate. More specifically, the conductive protrusion structure **560a** or the conductive protrusion structure **560b** is disposed on at least one of the first electrode **550a** of the substrate **500a** or the second electrode **550b** of the substrate **500b**. Further, the conductive protrusion structures **560a** and **560b** may be respectively disposed on the axes of symmetry of the electrode structures **550a** and **550b**. Given that the intensity of local electric field of the electrode structure **550** can be extended by the conductive protrusion structures **560a** and **560b**, the conductive protrusion struc-

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tures **560a** and **560b** may be disposed at other positions of the first electrode **550a** and the second electrode **550b**.

FIG. 6 shows a sectional view of a display device **60** according to an embodiment of the present invention. As shown in FIG. 6, the display device **60** includes a first base substrate **610a**, a second base substrate **610b**, an electrode structure **650a**, an electrode structure **650b**, a conductive protrusion structure **660a**, a conductive protrusion structure **660b** and a liquid crystal layer **680**. The second base substrate **610b** is disposed opposite to the first base substrate **610a**. The electrode structure **650a** includes a first electrode **630a**, an insulation layer **635a** and a second electrode **640a**. The first electrode **630a** is disposed on the first base substrate **610a**. The insulation layer **635a** is disposed on the first electrode **630a**. The second electrode **640a** is disposed on the insulation layer **635a**. The conductive protrusion structure **660a** is disposed on the second electrode layer **640a**. The electrode structure **650b** includes a first electrode **630b**, an insulation layer **635b** and a second electrode **640b**. The first electrode **630b** is disposed on the second base substrate **610b**. The insulation layer **635b** is disposed on the first electrode **630b**. The second electrode **640b** is disposed on the insulation layer **635b**. The conductive protrusion structure **660b** is disposed on the second electrode **640b**.

In this embodiment, the conductive protrusion structures **660a** and **660b** have substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. 1A and 1B, and associated details shall be omitted herein. The first base substrate **610a**, the insulation layer **635a**, the electrode structure **650a** and the conductive protrusion structure **660a** constitute a substrate **600a**. The second base substrate **610b**, the insulation layer **635b**, the electrode structure **650b** and the conductive protrusion structure **660b** constitute a substrate **600b**. In FIG. 6, the conductive protrusion structures **660a** and **660b** are respectively disposed on the axes of symmetry of the electrode structures **650a** and **650b**. However, the conductive protrusion structures **660a** and **660b** may be disposed at other positions of the electrode structures **650a** and **650b**. Alternatively, the conductive protrusion structure **660a** or the conductive protrusion structure **660b** may also be disposed between two electrode structures **650a** on the insulation layer **635a** or two electrode structures **650b** on the insulation layer **635b**. By applying voltages having different polarities to the two adjacent electrode structures **650a** or electrode structures **650b**, the two sides of the conductive protrusion structure **660a** or the conductive protrusion structure **660b** may carry electricity having different polarities as being induced by the electrode structures **650a** or the electrode structures **650b**, to improve the intensity of the local electric field.

FIG. 7 shows a sectional view of a display device **70** according to an embodiment of the present invention. The display device **70** includes a first base substrate **710a**, a second base substrate **710b**, an electrode structure **750**, a conductive protrusion structure **760** and a liquid crystal layer **780**. The second base substrate **710b** is disposed opposite to the first base substrate **710a**. The electrode structure **750** is disposed on the first base substrate **710a** having the conductive protrusion structure **760** thereon. For example, the electrode structure **750** includes a plurality of alternately arranged pixel electrodes and common electrodes. The conductive protrusion structure **760** is disposed on the first base substrate **710a** and disposed between the two adjacent electrode structures **750**. For example, the two adjacent electrode structures **750** are a pixel electrode and a common electrode. The liquid crystal layer **780** is disposed between the first base substrate **710a** and the second base substrate **710b**. The first base sub-

strate **710a**, the electrode structure **750** and the conductive protrusion structure **760** constitute a substrate **700**. In this embodiment, for example, the conductive protrusion structure **760** has substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. **1A** and **1B**, and associated details shall be omitted herein.

FIG. **8** shows a sectional view of a display device **80** according to an embodiment of the present invention. The display device **80** includes a first base substrate **810a**, a second base substrate **810b**, an electrode structure **850**, a conductive protrusion structure **860** and a liquid crystal layer **880**. The second base structure substrate **810b** is disposed opposite to the first base substrate **810a**. The electrode structure **850** is disposed on the first base substrate **810a** having the conductive protrusion structure **860** thereon. For example, the electrode structure **850** includes a plurality of alternately arranged pixel electrodes and common electrodes. The conductive protrusion structure **860** is disposed at an edge of the electrode structure **850**. For example, the two adjacent electrode structures **850** are a pixel electrode and a common electrode. The liquid crystal layer **880** is disposed between the first base substrate **810a** and the second base substrate **810b**. The first base substrate **810a**, the electrode structure **850** and the conductive protrusion structure **860** constitute a substrate **800**. In this embodiment, for example, the conductive protrusion structure **860** has substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. **1A** and **1B**, and associated details shall be omitted herein.

FIG. **9** shows a sectional view of a display device **90** according to an embodiment of the present invention. The display device **90** includes a first base substrate **910a**, a second base substrate **910b**, an electrode structure **950**, a conductive protrusion structure **960** and a liquid crystal layer **980**. The liquid crystal layer **980** is disposed between the first base substrate **910a** and the second base substrate **910b**. The second base substrate **910b** is disposed opposite to the first base substrate **910a**. The electrode structure **950** is disposed on the first base substrate **910a** having the conductive protrusion structure **960** thereon. For example, the electrode structure **950** includes a plurality of alternately arranged second electrodes **940**, an insulation layer **935** and a first electrode **930**. For example, the first electrode **930** and the second electrode **940** are one of pixel electrodes or common electrodes. The conductive protrusion structure **960** is disposed on a non-electrode region between two adjacent electrode structures **950**, and may be disposed on a surface of the first base substrate **910a**. For example, two adjacent electrode structures **950** may be a pixel electrode and a common electrode.

The first base substrate **910a**, the electrode structure **950** and the conductive protrusion structure **960** constitute a substrate **900**. In this embodiment, for example, the conductive protrusion structure **960** has substantially the same length, density and material as those of the conductive protrusion structure **160** in FIGS. **1A** and **1B**, and associated details shall be omitted herein. By applying voltages having different polarities to the two adjacent electrode structures **950**, the two sides of the conductive protrusion structure **960** may carry electricity having different polarities as being induced by the electrode structures **950**, to improve the intensity of the local electric field.

FIG. **10A** shows a sectional view of a substrate **1000** according to an embodiment of the present invention. As shown in FIG. **10A**, the substrate **1000** includes a base substrate **1010**, electrode structures **1050** and conductive protrusion structures **1060**. FIG. **10B** shows a top view of the sub-

strate **1000** in FIG. **10A**. The substrate **1000** is similar to the substrate **100** in FIG. **1A**, with a main difference being that the electrode structures **1050** of the substrate **1000** are rectangular bodies. The substrate **1000** may replace the substrates at either side of the display devices **10** to **90** in FIGS. **1A**, **1B**, **2** to **9**.

FIG. **11A** shows a sectional view of a substrate **1100** according to an embodiment of the present invention. As shown in FIG. **11A**, the substrate **1100** includes a base substrate **1110**, electrode structures **1150** and conductive protrusion structures **1160**. FIG. **11B** shows a top view of the substrate **1100** in FIG. **11A**. The substrate **1100** is similar to the substrate **100** in FIG. **1A**, with a main difference being that conductive protrusion structures **1160** of the substrate **1100** are disposed at two sides of the electrode structure **1150**. Thus, an issue of a dead zone of an electric field after applying a voltage can be solved. The conductive protrusion structures **1160** may be evenly or unevenly distributed, and may be arranged in a symmetrical or unsymmetrical manner at two sides of the electrode structures **1150** to adapt to manufacturing or product requirements. The substrate **1100** may substitute for the substrate at either side of the display device **10**, **20**, **30**, **40**, **50**, **60**, **70**, **80** or **90** in FIGS. **1A**, **1B**, **2** to **9**, respectively.

FIG. **12A** shows a sectional view of a substrate **1200** according to an embodiment of the present invention. As shown in FIG. **12A**, the substrate **1200** includes a base substrate **1210**, electrode structures **1250** and conductive protrusion structures **1260**. FIG. **12B** shows a top view of the substrate **1200** in FIG. **12A**. The substrate **1200** is similar to the substrate **1000** in FIG. **10A**, with a main difference being that the conductive protrusion structures **1260** of the substrate **1200** are disposed at two sides of the electrode structures **1250** to solve an issue of a dead zone of an electric field after applying a voltage.

In this embodiment, a distance **X** is between the conductive protrusion structure **1260** and an edge of the electrode structure **1250**, and the distance **X** ranges between **10 nm** and **10 μm**. A gap **P1** is between two rows of conductive protrusion structures **1260**, and the gap **P1** ranges between **0.01 μm** and **20 μm**. A gap **P2** is between every two conductive protrusion structures **1260** of the same row, and the gap **P2** ranges between **0.01 μm** and **20 μm**. In an embodiment, the conductive protrusion structures **1260** may be evenly or unevenly distributed, and the conductive protrusion structures **1260** may be arranged in a symmetrical or unsymmetrical manner at two sides of the electrode structure **1250** to adapt to manufacturing or product requirements. The substrate **1200** may substitute for the substrate at either side of the display device **10**, **20**, **30**, **40**, **50**, **60**, **70**, **80** or **90** in FIGS. **1A**, **1B**, **2** to **9**, respectively.

FIGS. **13** to **19** show schematic diagrams of an electrode structure and conductive protrusion structures according to different embodiments of the present invention. Referring to FIG. **13**, for example, a cross-section of the electrode structure **1350** is semi-circle shaped, and a plurality of conductive protrusion structures **1360** may be disposed on a surface of the electrode structure **1350**. In this embodiment, three rows of conductive protrusion structures **1360** disposed on the electrode structure **1350** are taken as an example. In other embodiments, more or fewer rows of conductive protrusion structures **1360** may be arranged on the electrode structure **1350** in an uneven and unsymmetrical manner to adapt to manufacturing and product requirements.

Referring to FIG. **14**, in an embodiment, a cross-section of an electrode structure **1450** may be a trapezoid, and a plurality of conductive protrusion structures **1460** may be disposed on

a surface of the electrode structure **1450**. Referring to FIG. **15**, in an embodiment, a cross-section of an electrode structure **1550** may be rectangle or square shaped, and a plurality of conductive protrusion structures **1560** may be disposed on a surface of the electrode structure **1550**. Referring to FIG. **16**, in an embodiment, a cross-section of an electrode structure **1650** may be a layer-stacked structure, and a plurality of conductive protrusion structures **1660** may be disposed on a surface of the electrode structure **1650**. In FIGS. **14** to **16**, the electrode structures **1450** to **1650** evenly arranged with three rows of conductive protrusion structures **1460** to **1660** are taken as examples. In other embodiments, more or fewer rows of conductive protrusion structures **1460** to **1660** may be arranged in an uneven and unsymmetrical manner on the electrode structures **1450** to **1640** electrode structures to adapt to manufacturing and product requirements.

Referring to FIG. **17**, in an embodiment, a cross-section of an electrode structure **1750** may be a layer-stacked structure (not shown), and a plurality of conductive protrusion structures **1760** may be provided on a surface of the electrode structure **1750**. Referring to FIG. **18**, in an embodiment, a cross-section of an electrode structure **1850** may be triangular shaped, and a plurality of conductive protrusion structures **1860** may be disposed on a surface of the electrode structure **1850**. In FIGS. **17** and **18**, the electrode structures **1750** and **1850** with two rows of conductive protrusion structures **1760** and **1860** arranged in an unsymmetrical or symmetrical manner are taken as examples. In other embodiments, more or fewer rows of conductive protrusion structures **1760** and **1860** may be evenly or unevenly arranged in a symmetrical manner on the electrode structures **1750** and **1850** to adapt to manufacturing and product requirements.

In an embodiment, a cross-section of an electrode structure **1950** may be T-shaped, and a plurality of conductive protrusion structures **1960** may be disposed on a surface of the electrode structure **1950**. In FIG. **19**, the electrode structure **1960** with a single row of conductive protrusion structures **1960** is taken as an example. In other embodiments, more or fewer rows of conductive protrusion structures **1960** may be evenly or unevenly arranged in a symmetrical manner on the electrode structure **1950** to adapt to manufacturing and product requirements.

FIGS. **20A** to **20E** show schematic diagrams of a conductive protrusion structure according to different embodiments of the present invention. Referring to FIG. **20A**, a conductive protrusion structure **2060a** may be polygonal cylinder shaped, e.g., hexagonal cylinder shaped in FIG. **20A**. Referring to FIG. **20B**, a conductive protrusion structure **2060b** may be a rod shaped structure having a spiral top end. Referring to FIG. **20C**, a conductive protrusion structure **2060c** may be a forked shape. Referring to FIG. **20D**, a conductive protrusion structure **2060d** may be a semicircular cylinder. Referring to FIG. **20E**, a conductive protrusion structure **2060e** may be column shaped (e.g., a carbon column) having a plurality of outwardly extending minute branches (e.g., zinc oxide). In an embodiment, the conductive protrusion structure may be a hair shaped or a pin shaped structure.

In summary, a substrate and a display device having such substrate are provided as described by the above embodiments of the present invention. Through arrangements of electrode structures and conductive protrusion structures, a part of an electric field is effectively reinforced to lower a driving voltage of the display device. An issue of a dead zone of an electric field is further mitigated by disposing the conductive protrusion structures on a surface of the electrode structures. Thus, without additionally increasing the driving voltage, a more uniform electric field having greater intensity

and a higher density is provided to thus expand and extend a range of an operating electric field as well as to lower the driving voltage.

While the invention has been described by way of example and in terms of the preferred embodiments, it is to be understood that the invention is not limited thereto. On the contrary, it is intended to cover various modifications and similar arrangements and procedures, and the scope of the appended claims therefore should be accorded the broadest interpretation so as to encompass all such modifications and similar arrangements and procedures.

What is claimed is:

1. A display device, comprising:

a first base substrate;

a second base substrate;

a liquid crystal layer, disposed between the first base substrate and the second base substrate;

an electrode structure, disposed on at least one of the first base substrate and the second base substrate; and

a conductive protrusion structure, disposed on at least one of the first base substrate, the second base substrate and the electrode structure, wherein the conductive protrusion structure comprises a plurality of conductive protrusions in a predetermined arrangement, a first gap between two adjacent rows of the conductive protrusions ranges between 0.01 μm and 20 μm , a second gap between the conductive protrusions of a same row ranges between 0.01 μm and 20 μm , and a density of the conductive protrusions is 10^{-2} to 10^6 conductive protrusions per 100 μm^2 .

2. The display device according to claim 1, wherein the electrode structure comprises:

a first electrode, disposed on the first base substrate; and

a second electrode, disposed on the second base substrate; wherein the conductive protrusion structure is disposed on at least one of the first electrode and the second electrode.

3. The display device according to claim 1, wherein the electrode structure comprises:

a first electrode, disposed on the first base substrate;

an insulation layer, disposed on the first electrode; and

a second electrode, disposed on the insulation layer; and the conductive protrusion structure is disposed on the insulation layer or the second electrode.

4. The display device according to claim 1, wherein the electrode structure comprises:

a pixel electrode, disposed on at least one of the first base substrate and the second base substrate; and

a common electrode, spaced from the pixel electrode and alternately disposed with the pixel electrode; and

the conductive protrusion structure is disposed between the pixel electrode and the common electrode, or is disposed on at least one of the pixel electrode and the common electrode.

5. The display device according to claim 1, wherein the electrode structure comprises a T-shaped, a trapezoidal shaped, a semicircular shaped, a rectangular shaped or a multi-layer composite structure; and the conductive protrusion structure comprises a metal oxide or a carbon nano-material, and carbon nano-material is a group selected from carbon-based nanomaterial, nano carbon fiber and nano carbon graphite.

6. The display device according to claim 5, wherein the conductive protrusion structure is a group selected from ferric oxide, titanium dioxide, copper oxide and indium tin oxide.

7. The display device according to claim 1, wherein the conductive protrusion structure has a thickness ranging

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between 10 nm and 1 μm , and the conductive protrusion structure has a length ranging between 100 nm and 10 μm .

8. The display device according to claim 1, wherein the conductive protrusion structure is a hair shaped, forked shaped, pin shaped or column shaped structure, and the column shaped conductive protrusion structure comprises a carbon column and a plurality of fiber shaped branches disposed on the carbon column.

9. The display device according to claim 1, wherein the conductive protrusion structure is disposed at an edge of the electrode structure or at an axis of symmetry of the electrode structure, and a distance between the conductive protrusion structure and the edge of the electrode structure ranges between 10 nm and 10 μm .

10. The display device according to claim 1, wherein the first base substrate comprises an electrode region and a non-electrode region, the electrode structure is disposed at the electrode region, and the conductive protrusion structure is disposed between the non-electrode region and the electrode region or on the non-electrode region.

11. A substrate, applied to a liquid crystal display (LCD) device, comprising:

a base substrate;

an electrode structure, disposed on the base substrate and adjacent to a liquid crystal layer of the LCD device; and a conductive protrusion structure, disposed on at least one of the base substrate and the electrode structure, wherein the conductive protrusion structure comprises a plurality of conductive protrusions in a predetermined arrangement, a first gap between two adjacent rows of the conductive protrusions ranges between 0.01 μm and 20 μm , a second gap between the conductive protrusions of a same row ranges between 0.01 μm and 20 μm , and a density of the conductive protrusions is 10^{-2} to 10^6 conductive protrusions per 100 μm^2 .

12. The substrate according to claim 11, wherein the conductive protrusion structure is disposed at an edge of the electrode structure or at an axis of symmetry of the electrode structure, and a distance between the conductive protrusion structure and the edge of the electrode structure ranges between 10 nm and 10 μm .

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13. The substrate according to claim 11, wherein the electrode structure comprises:

a first electrode, disposed on the base substrate;

an insulation layer, disposed on the first electrode; and

a second electrode, disposed on the insulation layer, and

the conductive protrusion structure is disposed on the insulation layer or the second electrode.

14. The substrate according to claim 11, wherein the electrode structure comprises:

a pixel electrode, disposed on the base substrate; and

a common electrode, spaced from the pixel electrode and alternately disposed with the pixel electrode; and

the conductive protrusion structure is disposed between the pixel electrode and the common electrode, or is disposed on at least one of the pixel electrode and the common electrode.

15. The substrate according to claim 11, wherein the electrode comprises a T-shaped, a trapezoidal shaped, a semicircular shaped, a rectangular shaped or a multi-layer composite structure, the conductive protrusion structure is a hair shaped, forked shaped, pin shaped or column shaped structure, and the column shaped conductive protrusion structure comprises a carbon column and a plurality of fiber shaped branches disposed on the carbon column.

16. The substrate according to claim 15, wherein the conductive protrusion structure comprises a metal oxide or a carbon nano-material, and the carbon nano-material is a group selected from carbon-based nanomaterial, nano carbon fiber and nano carbon graphite.

17. The substrate according to claim 11, wherein conductive protrusion structure has a thickness ranging between 10 nm and 1 μm and a length ranging between 100 nm and 10 μm .

18. The substrate according to claim 11, wherein the substrate comprises an electrode region and a non-electrode region, the electrode structure is disposed at the electrode region, and the conductive protrusion structure is disposed between the non-electrode region and the electrode region or on the non-electrode region.

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